

FLUE GAS ANALYSER - UVDOAS

GAUV-01

Environment Online Monitoring/Industrial Process Control/Safety Monitoring









Overview

GAUV-01 flue gas analyzer is developed for online gas analysis of environmental protection and industrial Control. Based on UV Differential Optical Absorption Spectroscopy (DOAS) technology and chemometrics Algorithm(PLS). It is able to measure gas concentration of SO2, NO, NO2, NH3, CL2, O2, H2S, CH4 etc. With features of high measurement accuracy, high reliability, fast response time, wide application scope, It can be widely applied in environment online monitoring, industrial process control, safety monitoring etc. As a result of years of flue gas analyzer research and combined with practical experience of thousands of Successful application cases, the analyzer has derived multiple types (standard type, low emission type, Ultra-low emission type and customized type to meet diverse requirements in different working condition.

■ Technical Principle

GAUV-01 flue gas analyzer adopts UV **DOAS** technology. The optical platform consists of light source, gas chamber. optical fiber spectrograph (inc. diaphragm, holographic grating, linear array detector) and other optical components. Refer the fig. 1,2,3.

Ultraviolet light emitted by light source enters gas chamber by optical window and absorbed by measuring sample gas flowing through the chamber. The light carrying sample absorption information will be gathered by lens and coupled into optical fiber and then transmits into spectrometer through fiber. After light splitting and photo-voltaic conversion, gas absorption spectrum is obtained.

The corresponding component concentration in gas can be calculated by analyzing spectrum.

Note: the difference amongst std. analyser, low and ultra-low analyzer is the optical path; for low emission, it adopts multiple return structure with 1m optical path; for ultra-low emission analyzer, it uses white cell structure with adjustable optical of 5-15m.

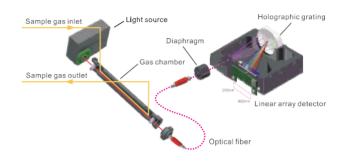


Fig.1 Standard (0.25m optical path)

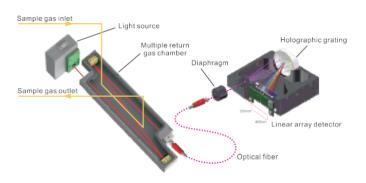


Fig.2 Low emission (1m optical path)

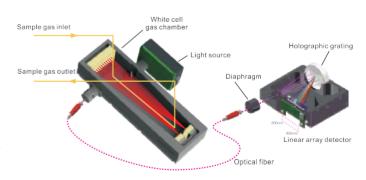


Fig.3 Ultra-low emission (5-15m optical path, adjustable)

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■ Technical Feature

High measurement accuracy

- Minimum detection limit of SO₂, NO, NO₂ can reach 1mg/m³ (15m optical path)
- Ultraviolet has no moisture absorption, undisturbed by moisture and dust
- No cross interference between measured gases (refer to table 1)
- Measure NO and NO2 simultaneously without converter
- · Low detection limit

High reliability

- · Small zero drift and span drift
- · Modular design
- · No optical moving parts, without vibration influence
- · Strong gas chamber, low cost
- Automatic adjustment spectrum technology, long maintenance-free period
- · Adopt pulse light source with 10-year service life

Table 1: Cross Interference between Gases Table

Measuring gas Interfering gas	SO_2	NO	NO_2	O_2
SO ₂ (500ppm)	/	< 1 ppm	no	no
NO (500ppm)	no	/	no	no
NO ₂ (500ppm)	no	< 1 ppm	/	no
H ₂ O (No dew)	no	no	no	no
CO (1000ppm)	no	no	no	no
CO ₂ (20%)	no	no	no	no
O ₂ (21%)	no	no	no	/

Wide application scope

- · Coal-fired power plant
- · Cement plant
- · Industrial furnace
- DeSO_x process monitoring
- DeNO_x process monitoring
- · Waste incineration plant
- PVC process in chlor-alkali plant
- Titanium dioxide production process
- Sulfur recovery process
- · Natural gas purification process
- · Methyl iodide analysis for the coal chemical industry
- On-line air monitoring

■ Technology Comparison

NDIR Technology	FTIR Technology	UVF + Chemiluminescence Technology	UV DOAS	
Low cost	High cost	High cost	Low cost	
Measure fewer components, generally, single gas chamber can only measure one kind	The largest advantage is able to measure over 10 components	Measure fewer components, different component adopt different measuring principle	The single gas chamber can measure 3-5 components	
With optical moving parts, poor reliability	The interferometer is optical moving part	No optical moving parts	Adopt full spectrum electronic scanning, without optical moving parts	
Single or dual wavelength	Full infrared spectrum measurement	Sensitive to some interferences, such as background fluorescence, quenching effect, and etc.	Full UV spectrum measurement technology, not affected by cross interference	
Fast response, long preheating time	Restricted by scanning time, slow response, need preheating	Fast response, poor stability and reproducibility caused by high light background	Fast response, no preheating	
Low measurement accuracy, large drift	High measurement accuracy and small drift	High measurement accuracy and large drift	High measurement accuracy, small drift	
High requirements for measured gas, no dust and low dew point	High requirements for measured gas, no dust and low dew point	High requirements for measured gas, no dust and low dew point	Water and a small amount of dust will not affect measurement	
Adopt continuous light source, service life is only thousands of hours	Adopt continuous light source, service life is only thousands of hours	Adopt continuous light source, service life is only thousands of hours	Adopt pulse light source, with service life of ten years	
High detection limit	Low detection limit	Low detection limit	Low detection limit, the minimum can reach 1 mg/m ³	

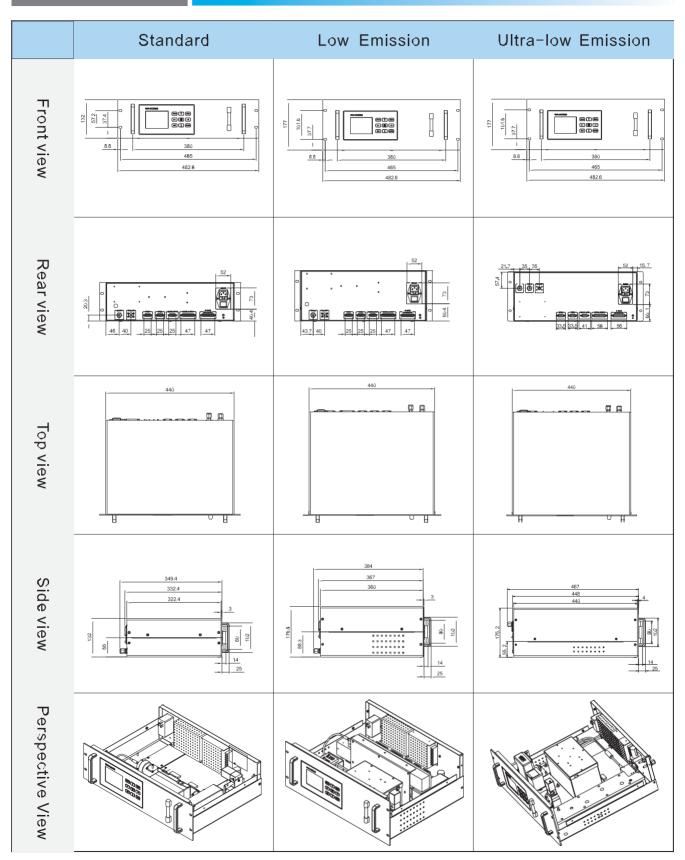


■ Technical Specification

		Standard		Low Emission		Ultra-lo	Ultra-low Emission	
Appearance		Benx 3		anx 1		Denta		
Measurement Principle				UV-DO	AS+PLS	<u> </u>		
Typical measurement		Min range	Max range	Min range	Max range	Min range	Max range	
	SO ₂	0~300ppm	0 ~ 3000ppm	0 ~ 100ppm	0~300ppm	0 ~ 50ppm	0 ~ 100ppm	
Commonant	NO	0 ~ 300ppm	0 ~ 3000ppm	0 ~ 100ppm	0 ~ 300ppm	0 ~ 50ppm	0 ~ 100ppm	
Component	NO ₂	0 ~ 500ppm	0 ~ 4000ppm	0~300ppm	0 ~ 1000ppm	0 ~ 100ppm	0 ~ 200ppm	
	O ₂	0 ~ 5%	0 ~ 25%	0 ~ 5%	0 ~ 25%	0 ~ 5%	0~25%	
Linearity		≤ ± 3%F.S.						
Repeatabilit	у	≤2%						
Zero Drift		≤ ± 2%F.S./7d						
Span Drift		≤ ± 2%F.S./7d						
Response Ti	me(T90)	≤50s						
Working Tem	perature	-20°C ~ +50°C						
Preheating Time		No pre	No preheating 20min 40min			0min		
Sample Gas Interface		Φ6 Bi-Lok						
Sample Gas	Flow	Range: (0.5 ~ 2)L/min, fluctuation < 25%						
Sample Gas	Pressure	Current ambient pressure ± 0.1Bar						
Sample Gas	Temperature	e 0℃~ +50℃						
Sample Gas	Humidity	No condensation (under sample gas temperature)						
4–20mA Inpu	ut Interface	3 , configurable, 100Ω load						
4–20mA Out	put Interface	5, output content can be configured, maximum load capacity ≤800 Ω						
Switch Input	Interface	6 , configurable						
Relay Outpu	t Interface	14, output content can be configured. DC30V2A						
Communicat	ion Interface	1×RS232, 1×RS485 (Support Modbus protocol)						
Installation N	Method	Installed in 19 inch cabinet						
Supply Voltage 220VAC ± 10%								
Rated Power Abo			ut 100W	About 120W				
Dimension		132(H)x483	(W)x375(D)mm	177(H)x483(W)x412(D)mm 177(H)x483(W)x49		B(W)x492(D)mm		
Weight		About 10kg About 15kg						

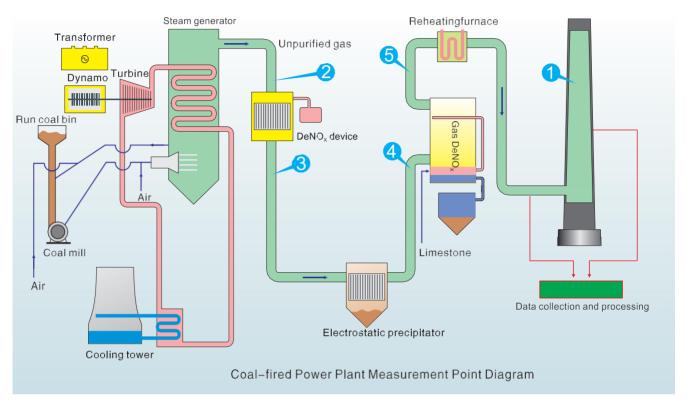


■ External Dimension



Typical Application

Coal-fired power plant is the major emission source of atmospheric pollution, including particulate matter, SO_2 , NO_X and etc. It affects economic development and damages both living as well as ecological environment. The main method for controlling process and exhaust emission to reach ultra-low discharge standard and optimize process is through gas component monitoring.



Measurement Point No.	Detection Point	Temp	Pressure	Measuring component	Monitoring Purpose
Point 1	Main emission stack	Normal	Micro-positive pressure	CEMS (five-parameter)	Online monitor emission of each component in exhaust gas
Point 2	Before DeNO _x	Normal	Micro-positive pressure	NO _x , O ₂	Monitor efficiency of DeNO _x device in real time
Point 3	After DeNO _x	Normal	Micro-positive pressure	NO _x , O ₂ , NH ₃	Monitor efficiency of DeNO _x device in real time
Point 4	Before DeNO _x	Normal	Micro-positive pressure	So ₂ , O ₂	Monitor efficiency of DeNO _x device in real time
Point 5	After DeNO _x	Normal	Micro-positive pressure	So ₂ , O ₂	Monitor efficiency of DeNO _x device in real time

*For detail, please refer to selection our manual and product sample $\,$

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